

TECHNICAL PROGRAM

MONDAY, DECEMBER 8TH, 2014		PART NO.
08:00-08:20	OPENING – WELCOME - INTRODUCTION L.P.H. Jeurgens¹, J. Janczak-Rusch¹, Y.N. Zhou², A. Hirose³ ¹ <i>Empa, Swiss Federal Laboratories for Materials Science and Technology, Switzerland</i> ² <i>University of Waterloo, Centre for Advanced Materials Joining, Canada</i> ³ <i>Osaka University, Division of Materials and Manufacturing Science, Japan</i>	CHAIRS
Session	ORAL SESSION I (PLENARY)	
Room	SEEBLICK	
Chair	Y.N. Zhou, L.P.H. Jeurgens	
08:20	ASSEMBLY AND PACKAGING TECHNOLOGIES FOR POWER DEVICES AND MODULES Y. Kashiba <i>Manufacturing Engineering Center, Mitsubishi Electric Corporation, Japan</i>	KEYNOTE K1
09:00	HIGH TEMPERATURE VIABLE INTERCONNECTION REALIZED BY SINTERING Sn-M IMC NANOALLOYS AT LOW TEMPERATURE C. Wang, Y. Zhong, Z. Zheng <i>State Key Lab. of Advanced Welding & Joining, Harbin Institute of Technology, China</i>	KEYNOTE K2
09:40	SYNTHESIS AND CHARACTERIZATION OF NANOTHERMITE FOR MICRO-JOINING APPLICATIONS J.Z. Wen <i>Dept. of Mechanical & Mechatronics Engineering, University of Waterloo, Canada</i>	INVITED I4
10:00-10:30	COFFEE BREAK	
Session	ORAL SESSION II (PLENARY)	
Room	SEEBLICK	
Chair	A. Hirose, J. Janczak-Rusch	
10:30	SIZE EFFECTS ON THE THERMODYNAMIC PROPERTIES OF NANOALLOYS C. Ricolleau¹, G. Prévot², J. Nelayah¹, G. Wang¹, D. Alloyeau¹ ¹ <i>Laboratoire Matériaux et Phénomènes Quantiques, Université Paris 7 – CNRS, France</i> ² <i>Institut des Nanosciences de Paris, Université Paris 6 – CNRS, France</i>	INVITED I2
10:50	MICROSTRUCTURAL EVOLUTION OF NANO-STRUCTURED Ag-Cu/AlN BRAZING FILLERS UPON HEATING M. Lewandowska¹, M. Andrzejczuk¹, G. Pigozzi², L.P.H. Jeurgens², J. Janczak-Rusch² ¹ <i>Warsaw University of Technology, Faculty of Materials Science and Engineering, Poland</i> ² <i>Empa, Swiss Federal Laboratories for Materials Science and Technology, Switzerland.</i>	INVITED I3
11:10	SILVER SINTER JOINING AND NEW THIN FILM BONDING FOR WBG DIE-ATTACH K. Suganuma, S. Nagao, T. Sugahara, C. Oh, H. Zhang, S. Koga, S. Park <i>Institute of Scientific and Industrial Research, Osaka University, Japan</i>	INVITED I5
11:30	COPPER NANOCOMPOSITE PASTE FOR HIGH RELIABLE INTERCONNECTION AND ITS JOINING CHARACTERISTICS K.-S. Kim, S.-B. Jung <i>School of Advanced Materials Science and Eng., Sungkyunkwan University, Republic of Korea</i>	RO
11:50	NANO BRAZING TECHNOLOGY IN INDUSTRIAL ENVIRONMENT M. TÜRPE <i>MAHLE Behr GmbH & Co. KG, Stuttgart, Germany</i>	R1
12:10-13:30	LUNCH	

MONDAY, DECEMBER 8TH, 2014		PART NO.
Session	ORAL SESSION III (PLENARY)	
Room	SEEBLICK	
Chair	G. Zou, W. Tillmann	
13:30	BRIDGING THE GAP BETWEEN ATOMISTICS AND THERMODYNAMICS OF INTERFACES TO CONTROL WETTING AND PHASE FORMATION FOR METAL-CERAMIC JOINS <u>W.D. Kaplan</u> <i>Israel Institut of Technology, Israel</i>	KEYNOTE K3
14:10	STATE-OF-THE-ART LOCAL ELECTROCHEMICAL CHARACTERISATION OF MICRO- AND NANO-JOINTS <u>T. Suter, P. Schmutz, J. Janczak-Rusch</u> <i>Empa, Swiss Federal Laboratories for Materials Science and Technology, Switzerland</i>	R2
14:30	JOINING TECHNOLOGY THROUGH SINTERING OF SILVER NANOPARTICLES DERIVED FROM SILVER OXIDE PASTE <u>T. Ogura, A. Hirose</u> <i>Division of Materials and Manufacturing Science, Graduate School of Engineering, Osaka University, Japan</i>	R3
14:50	JOINING OF COPPER BY AG NANOPASTE: MICROSTRUCTURE AND STRENGTH BEHAVIOUR <u>B. Wielage, S. Weis, H. Podlesak, S. Hausner</u> <i>Institute of Materials Science and Engineering, Germany</i>	R4
15:10	SYNTHESIS AND LIGHT INDUCED NANOJOINING OF SILVER NANOWIRES <u>Y. Tian, S. Ding, C. Wang</u> <i>State Key Laboratory of Advanced Welding and Joining, Harbin institute of technology, China</i>	R5
15:30-16:00	COFFEE BREAK	
Session	ORAL SESSION IV (PLENARY)	
Room	SEEBLICK	
Chair	A. Hu, B. Wielage	
16:00	RELIABILITY OF LEAD-FREE SOLDER JOINTS IN MICROELECTRONICS <u>E. Hodúlová, B. Šimeková, I. Kovaříková</u> <i>Slovak University of Technology in Bratislava, Faculty of Materials Science and Technology in Trnava Institute of Production Technologies, Slovak Republic</i>	INVITED 16
16:20	WIREBONDER-MADE MICRO ELECTRO MECHANICAL SYSTEMS <u>J.G. Korvink¹, U. Wallrabe²</u> ¹ University of Freiburg, Dept. of Microsystems Eng., Laboratory for Simulation, Germany ² University of Freiburg, Dept. of Microsystems Eng., Laboratory for Microactuator, Germany	INVITED 17
16:40	EFFECT OF RAPID SOLIDIFICATION ON MICROSTRUCTURE AND PROPERTIES OF Sn-Ag-Cu LEAD-FREE SOLDER <u>S. Lu, F.J. Wang, Z.X. Zheng</u> <i>Provincial Key Laboratory of Advanced Welding Technology, Jiangsu University of Science and Technology, China</i>	R6
17:00	LEAD FREE BGAS SOLDERED WITH SnPb SOLDER <u>G. Grossmann¹, G. Nicoletti</u> <i>EMPA, Swiss Federal Laboratories for Materials Science and Technology, Switzerland</i>	R7
17:20	EFFECT OF ISOTHERMAL AGING ON IMPACT STRENGTH OF Sn-Ag-Cu SOLDER BUMPS <u>J.X. Wang^{1,2}, H. Nishikawa²</u> ¹ Jiangsu Provincial Key Laboratory of Advanced Welding Technology, Jiangsu University of Science and Technology, China ² Joining and Welding Research Institute, Osaka University, Japan	R8
17:40	EFFECT OF THERMAL TREATMENT ON Cu EXTRUSION OF TSV AND SOLDER BUMPING FOR THREE-DIMENSIONAL PACKAGING <u>S.H. Kee, M.H. Roh, S.J. Lee, J.P. Jung, W.J. Kim</u> <i>Dept. of Materials Science and Engineering, University of Seoul, Korea</i>	R9
18:00-19:00	BREAK	
19:00	DINNER & SOCIAL EVENT (TORCH-LIT WALK)	

	TUESDAY, DECEMBER 9th, 2014	PART NO.
Session	ORAL SESSION V (PLENARY)	
Room	SEEBLICK	
Chair	M. Mayer, P. Gröning	
08:20	FEMTOSECOND LASER NANOSTRUCTURING, PRINTING OF NANOPARTICLES, AND MICRO-JOINING B. Chichkov <i>Laser Zentrum Hannover e.V., Germany</i>	KEYNOTE K4
09:00	FORMATION AND CHARACTERIZATION OF SUBCLUSTER SEGREGATED NANOALLOY WITH FEMTOSECOND LASER IRRADIATION Z. Jiao^{1,2}, W. Duley³, N. Zhou^{2,4}, P. He¹ ¹ <i>State Key Laboratory of Advanced Welding Production Technology, Harbin Institute of Technology, Harbin 150001, China</i> ² <i>Centre for Advanced Materials Joining, University of Waterloo, Canada</i> ³ <i>Dept. of Physics & Astronomy, University of Waterloo, Canada</i> ⁴ <i>Dept. of Mechanical and Mechatronics Engineering, University of Waterloo, Canada</i>	INVITED I8
09:20	ULTRA-LOW POWER INTEGRATED PH NANOSENSORS A.M. Ionescu, S. Rigante, E. Buitrago <i>Nanolab, Ecole Polytechnique Fédérale de Lausanne, Switzerland</i>	INVITED I9
09:40	GROWTH AND ASSEMBLY OF GRAPHENE THIN FILMS ON INSULATING SUBSTRATES T. Ogino <i>Division of Electrical and Computer Engineering, Yokohama National University, Japan</i>	INVITED I10
10:00-10:30	COFFEE BREAK	
Session	ORAL SESSION VI (PLENARY)	
Room	SEEBLICK	
Chair	F. Baras, H. Nishikawa	
10:30	JOINING REFRACTORY AND DISSIMILAR MATERIALS USING REACTIVE NANOFOILS A.S. Rogachev^{1,2}, A.S. Mukasyan^{2,3}, S.G. Vadchenko¹, A.A. Nepapushev² ¹ <i>Inst. of Structural Macrokinetics & Material Science Russian Academy of Science (ISMAN), Russia</i> ² <i>Center of Functional Nano-Ceramics, National University of Science and Techn., "MISIS", Russia</i> ³ <i>Dept. of Chemical and Biomolecular Engineering, University of Notre Dame, USA</i>	INVITED I11
10:50	ADVANCED NANOSTRUCTURE FORMATION VIA INTERFACE AND GRAIN BOUNDARY TAILORING S. Baylan¹, G. Richter¹, M. Beregovsky², D. Amram², E. Rabkin² ¹ <i>Max Planck Institute for Intelligent Systems, Germany</i> ² <i>Dept. of Materials Science and Engineering, Technion, Israel</i>	INVITED I12
11:10	NANOJOINING: FROM NANOSINTERING TO 3D NANOMANUFACTURING A. Hu¹, R. Li^{1,2}, Q. Ma¹, D. Bridges¹ ¹ <i>Dept. of Mechanical, Aerospace and Biomedical Eng., University of Tennessee Knoxville, USA</i> ² <i>Dept. of Electrical Engineering, Southeast University, China</i>	INVITED I13
11:30	PATTERNING OF INDIUM TIN OXIDE MICROWIRES USING LASER-INDUCED THERMAL PRINTING METHOD T. Sano¹, S. Iwasaki¹, S. Katsura², K. Yoshida³, A. Nakayama⁴, A. Hirose¹ ¹ <i>Div. of Materials and Manufacturing Science, Graduate School of Eng., Osaka University, Japan</i> ² <i>Nippon Denki Kagaku Co., Japan</i> ³ <i>General Co., Ltd., Japan</i> ⁴ <i>Ion Technology Center Co., Ltd., Japan</i>	INVITED I14
11:50	EX- AND IN-SITU X-RAY BASED ANALYTICAL STUDIES ON SOLDER MATERIALS FOR MICROSYSTEMS PACKAGING APPLICATIONS A. Neels¹, T. Bandi², R. Kaufmann¹, J. Janczak-Rusch¹, L.P.H. Jeurgens¹, A. Dommann¹ ¹ <i>Empa, Swiss Federal Laboratories for Materials Science and Technology, Switzerland</i> ² <i>SSC, Ecole Polytechnique Fédérale de Lausanne (EPFL), Switzerland</i>	R10
12:10-13:30	LUNCH	

	TUESDAY, DECEMBER 9th, 2014	PART NO.
Session	ORAL SESSION VII (PARALLEL)	
Room	WALDHORN (ROOM 1)	
Chair	L. Quintino, J-P. Jung	
13:30	SOLID-LIQUID DIFFUSION BONDING OF COPPER USING Sn/Ag MULTILAYERED FILMS S. Fukumoto¹, K. Miyake², M. Matsushima¹, K. Fujimoto¹ ¹ Graduate School of Engineering, Osaka University, JAPAN ² Graduate Student of Osaka University, JAPAN	R12
13:50	NANO-SIZE Ag/AIN MULTILAYERS FOR LOW TEMPERATURE JOINING APPLICATIONS M. Chiodi, F. Moszner, C. Cancellieri, G. Pigozzi, J. Janczak-Rusch, L.P.H. Jeurgens <i>Empa, Swiss Federal Laboratories for Materials Science and Technology, Switzerland</i>	R14
14:10	AQUEOUS Cu NANOPARTICLE INK STABILIZED BY PVP-SDS A.Y. Li^{1,2}, B.H. Wang², C. Yao Huo² ¹ State Key Laboratory of Advanced Welding & Joining, School of Materials Science & Engineering Harbin Institute of Technology, China ² School of Materials Science and Engineering, Harbin Institute of Technology at Weihai, China	R16
14:30	MELTING, MIXING AND NUCLEATION AT INTERFACES IN Ni-AI NANOFOILS : A MOLECULAR DYNAMICS APPROACH V. Turlo, O. Politano, F. Baras <i>Laboratoire ICB, UMR 6303 CNRS-Université de Bourgogne, FRANCE</i>	R18
14:50	START TEMPERATURE MANIPULATION AND EFFICIENCY IMPROVING OF SELF-PROPAGATION CHEMICAL REACTIONS IN MULTILAYERED THERMITE MATERIALS BASED ON ALUMINUM-COPPER NITRIDE COMPOSITE D.G. Gromov¹, E.A. Lebedev¹, S.P. Timoshenkov¹, Y.I. Shilyaeva¹, V.A. Galperin², D.I. Smirnov³, E.P. Kirilenko⁴ ¹ National Research University of Electronic Technology, Russia ² Science Manufacturing complex "Technological Center", Russia ³ Lebedev Physical Institute of Russian Academy of Science, Russia ⁴ Science-Technological center "Nano- and Microsystems technics", Russia	R20
15:10	INVESTIGATION OF COPPER-BASED NANOSTRUCTURED MULTILAYER SYSTEMS FOR BRAZING APPLICATIONS W. Tillmann, B. Lehmert, L. Wojarski, M. Kuck <i>TU Dortmund, Institute of Materials Engineering, Germany</i>	R22
15:30-16:00	Coffee Break	
Session	ORAL SESSION VIII (PARALLEL)	
Room	WALDHORN (ROOM 1)	
Chairperson	P. He, M. Yavuz	
16:00	FEMTOSECOND LASER INDUCED NANOJOINING L. Liu^{1,2}, L. Lin¹, D. Shen¹, H. Bai¹, G. Zou¹, Y.N. Zhou³ ¹ Dept. of Mechanical Engineering, Tsinghua University, China ² The State Key Laboratory of Tribology, Tsinghua University, China ³ Dept. of Mechanical & Mechatronics Engineering, University of Waterloo, Canada	R24
16:20	TRANSIENT THERMAL IMPEDANCE OF IGBT MODULES JOINED BY LEAD-FREE SOLDER AND SINTERED NANOSILVER M.Y. Wang¹, Y.H. Mei¹, X. Li¹, G.Q. Lu^{1,2} ¹ Tianjin Key Laboratory of Advanced Joining Technology, School of Material Science and Engineering, Tianjin University, China ² Dept. of Material Science and Engineering, Virginia Tech, USA	R26
16:40	LASER ASSISTED LOW TEMPERATURE HERMETIC SEALING OF OPTOELECTRONICS DEVICES R. Jose James¹, E. Rutz¹, T. Stadelmann¹, S. Berchtold¹, M. Lützelshwab¹, Ch. Bosshard¹, M. Epitoux², A. Hold², C. Vélez² ¹ CSEM SA, Switzerland ² Exalos AG, Switzerland	R28
17:00	EFFECTS OF HEAT TREATMENT ON RESISTANCE MICROWELDING JOINTS OF CROSSED NITINOL WIRES Y. Huang^{1,2}, A. Pequegnat², N. Zhou² ¹ National Defense Key Disciplines Laboratory of Light Alloy Processing Science and Techn. Nanchang Hangkong University, China ² Centre for Advanced Materials Joining, University of Waterloo, Canada	R30
17:20	Transfer to Poster Session SEEBLICKSAAL	
17:30	POSTER SESSION SEEBLICK	

	TUESDAY, DECEMBER 9th, 2014	PART NO.
Session	ORAL SESSION IX (PARALLEL)	
Room	ZEDER (ROOM 2)	
Chairperson	T. Ogura, G. Grossmann	
13:30	IMPROVEMENT OF IMPACT RELIABILITY OF SOLDER BUMPS USING LASER PROCESS H. Nishikawa¹, N. Iwata² ¹ Joining and Welding Research Institute, Osaka University, Japan ² Graduate School of Engineering, Osaka University, Japan	R13
13:50	DISPLACEMENT ANALYSIS OF BONDING WIRES UNDER DC CURRENT T. Dagdelen¹, M. Khater², S. Park², R. Saritas¹, E. Abdel-Rahman², M. Yavuz¹ ¹ Mechanical and Mechatronics Engineering Department, University of Waterloo, Canada ² Department of System Design Engineering, University of Waterloo, Canada	R15
14:10	INTERMETALLIC COMPOUND JOINTS PRODUCED BY ULTRASONIC SOLDERING PROCESS IN Cu/Sn/Cu SYSTEM M. Li^{1,2}, Z. Li¹, C. Wang² ¹ Shenzhen Key Laboratory of Advanced Materials, Harbin Institute of Technology Shenzhen Graduate School, HIT Campus, The University Town of Shenzhen, China ² State Key Laboratory of Advanced Welding and Joining, Harbin Inst. of Techn., China	R17
14:30	MECHANICAL RESPONSE ON Cu-Sn INTERMETALLICS F. Wang, X. Li, and K. Qi Provincial Key Lab. of Adv. Welding Techn., Jiangsu University of Science & Techn., China	R19
14:50	SHEAR STRENGTH DEGRADATION OF Pb-FREE SOLDER JOINT WITH MOUNTED LOCATION IN AUTOMOBILE W.S. Hong, A Young Kim Components & Materials Physics Research Center, Korea Electronics Technology Institute	R21
15:10	3D STEREO LITHOGRAPHIC PRINTING OF TERAHERTZ WAVE PHOTONIC CRYSTALS THROUGH MICRO JOINING OF OXIDE AND METALLIC GLASSES S. Kirihara Joining and Welding Research Institute, Osaka University, Japan	R23
15:30-16:00	Coffee Break	
Session	ORAL SESSION X (PARALLEL)	
Room	ZEDER (ROOM 2)	
Chairperson	D.G. Gromov, T. Sano	
16:00	INSPECTION OF MICRO DEFECTS USING BACTERIAL CELLS T.G. Santos¹, R.M. Miranda¹, L. Quintino², C.C.C.R. de Carvalho³ ¹ UNIDEMI, Departamento de Engenharia Médica e Industrial, Faculdade de Ciências e Tecnologia, Universidade Nova de Lisboa, Portugal ² IDMEC, Instituto Superior Técnico, Universidade de Lisboa, Portugal ³ Institute of Biotechnology and Bioengineering, Centre for Biological and Chemical Eng., Dept. of Bioengineering, Instituto Superior Técnico, Universidade de Lisboa, Portugal	R25
16:20	STABILITY AND MELTING OF FCC TRUNCATED OCTAHEDRAL AG NANOPARTICLES BY MOLECULAR DYNAMICS SIMULATION H. Alarifi¹, M. Atiş², C. Özdoğan³, A. Hu⁴, M. Yavuz⁵, Y. Zhou⁵ ¹ King Abdulaziz City for Science and Technology, Saudi Arabia ² Kayseri Vocational School, Dept. of Electricity and Energy, Erciyes University, Turkey ³ Dept. Materials Science and Engineering, Cankaya University, Turkey ⁴ Dept. Mechanical, Aerospace & Biomedical Eng., University of Tennessee Knoxville, USA ⁵ Dept. Mech. & Mechatronics Eng., Centre for Adv. Mater. Joining, Univ. of Waterloo, Canada	R27
16:40	NUMERICAL ANALYSIS OF MICROBUBBLE BEHAVIOR AND MICROPOROSITY FORMATION IN LASER BEAM WELDS OF ALUMINIUM ALLOY H. Mori¹, Q. Zhou¹, K. Koyama¹, F. Miyasaka², Y. Murakami³, Y. Kawahito³, M. Mizutani³, S. Katayama³ ¹ Osaka University, Graduate School of Eng., Dept. of Mngt. of Industry & Techn., Japan ² Osaka University, Department of Adaptive Machine Systems, Japan ³ Osaka University, Joining and Welding Research Institute, Japan	R29
17:00	EFFECT OF ITO INTERLAYER ON THE Au/Hg₃In₂Te₆ SCHOTTKY CONTACT CHARACTERISTICS L. Yapeng, C. Liu, L. Fu State Key Laboratory of Solidification Processing, School of Materials Science & Eng. Northwestern Polytechnical University, China	R31
17:20	Transfer to Poster Session SEEBLICKSAAL	
17:30	POSTER SESSION SEEBLICK	

	TUESDAY, DECEMBER 9th, 2014	PART NO.
Session	POSTER SESSION	
18:00	<p>LOW-TEMPERATURE COMBUSTION JOINING OF CARBON/CARBON COMPOSITES A.A. Nepapushev¹, Ya-Cheng Lin², A.S. Rogachev^{1,3}, P.J. McGinn², A.S. Mukasyan^{1,2}, ¹National University of Science and Technology, Russia ²Dept. Chem. & Biomolec. Eng., University of Notre Dame, USA ³Inst. of Structural Macrokineitics & Materials Science Russian Acad. of Sciences, Russia</p>	P1
	<p>THE MECHANISM OF MELTING POINT DEPRESSION AISi/AIN IN NANOMULTILAYERED SYSTEMS J. Lipecka¹, J. Janczak-Rusch^{1,2}, M. Andrzejczuk¹, M. Lewandowska¹, G. Richter³, L.P.H. Jeurgens² ¹Warsaw University of Technology, Poland ²Empa, Swiss Federal Laboratories for Materials Science and Technology, Switzerland ³Max Planck Institute for Intelligent Systems, Germany</p>	P2
	<p>EFFECTS OF WARPAGE ON HIP DURING BGA PACKAGING Z. Zhao¹, Ch. Chen², Y. Wang³, Ch.Y. Park⁴, L. Liu¹, J. Cai², Q. Wang², H. Bai¹, G. Zou¹ ¹Dept. of Mechanical Engineering, Tsinghua University, China ²Institute of Microelectronics, Tsinghua University, China ³Training Center for Basic Industry, Tsinghua University, China ⁴Samsung Electronics Co. Ltd, Korea</p>	P3
	<p>INVESTIGATION OF MEMORY EFFECT IN THE Ge₂Sb₂Te₅ THIN FILMS BY DC AND PULSE MEASUREMENTS P. Lazarenko¹, A. Sherchenkov¹, S. Kozyukhin², S. Timoshenkov¹, D. Gromov¹, M. Michaylova¹ ¹National Research University of Electronic Technology (MIET), Russia ²Kurnakov Institute of General and Inorganic Chemistry, RAS, Russia</p>	P4
	<p>RECENT R&D RESULTS OF TSINGHUA-FLEXTRONICS SMT LAB Y. Wang, T. Wang Training Center for Basic Industry, Tsinghua University, Beijing 100084, China</p>	P5
	<p>RECENT ACHIEVEMENTS IN NANO/MICRO JOINING RESEARCHES A. Hirose, T. Sano, T. Ogura Intelligent Manufacturing Process Group of Osaka University, Japan</p>	P6
	<p>HERMETIC TLP BONDING OF MEMS FOR HARSH ENVIRONMENTS G. Spinola Durante¹, R. Jose James¹, S. Mohrdiek¹, M. Despont², P. Niedermann² ¹CSEM SA Alpnach, Switzerland ²CSEM SA Neuchâtel, Switzerland</p>	P8
	<p>LASER INDUCED MICROJOINING H. Bai¹, L. Liu^{1,2}, G. Zou¹, and Y.N. Zhou³ ¹Dept. of Mechanical Engineering, Tsinghua University, China ²The State Key Laboratory of Tribology, Tsinghua University, China ³Dept. of Mechanical & Mechatronics Engineering, University of Waterloo, Canada</p>	P9
	<p>PREPARATION AND SEALING OF POLYMER MICROCHANNELS USING EB LITHOGRAPHY TO PATTERN ABSORBER FOR LASER WELDING I. A. Jones¹, J. Griffiths² ¹TWI Ltd, Granta Park, UK ²Cavendish Laboratory, University of Cambridge, UK</p>	P10
	<p>BONDABILITY OF Mg₂Si THERMOELECTRIC ELEMENT AND NI ELECTRODE USING AI T. Tohei¹, S. Fujiwara¹, M. Tominaga², T. Jinushi², Z. Ishijima³ ¹Hitachi Ltd., Yokohama Research Laboratory, Japan ²Hitachi Chemical Co., Ltd., Hitachi Powdered Metals, Japan ³Hitachi Chemical Co., Ltd., Japan</p>	P11
	<p>WETTING PROPERTIES OF BOROSILICATE GLASS ON MICROSTRUCTURED KOVAR SURFACES BY HIGH-ENERGY DENSITY BEAM TEXTURING H. Li¹, M. Tie¹, Z. Li¹ and W. Tillmann² ¹College of materials science and engineering, Beijing University of Technology, China ²Dortmund University of Technology, Germany</p>	P12
	<p>RECENT ADVANCES IN MICRO- AND NANOJOINING TECHNOLOGIES AT EMPA AND UNIVERSITY OF WATERLOO L.P.H. Jeurgens¹, Y. N. Zhou², J. Janczak-Rusch¹ ¹Empa, Swiss Federal Laboratories for Materials Science and Technology, Switzerland ²University of Waterloo, Centre for Advanced Materials Joining, Canada</p>	P13
19:00	Break	
20:00	SWISS GALA DINNER	